

MOSFET

Metal Oxide Semiconductor Field Effect Transistor

Bare Die

OptiMOS™3 Power MOS Transistor Chip IPC014N03L3

Data Sheet

Rev. 2.5 Final



IPC014N03L3

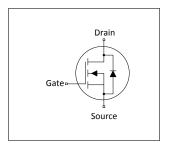
Description 1

- N-channel enhancement mode
- For dynamic characterization refer to the datasheet of IPD135N03LG
- AQL 0.65 for visual inspection according to failure catalogue
- Electrostatic Discharge Sensitive Device according to MIL-STD 883C
- Die bond: soldered or glued
- Backside metallization: NiV systemFrontside metallization: AlCu system
- Passivation: nitride + imide



Parameter	Value	Unit
V _{(BR)DSS}	30	V
R _{DS(on)}	13.5 ¹⁾	mΩ
Die size	1.64 x 0.845	mm ²
Thickness	175	μm











Type / Ordering Code	Package	Marking	Related Links
IPC014N03L3	Chip	not defined	-

Electrical Characteristics on Wafer Level

at $T_i = 25$ °C, unless otherwise specified

Table 2

Parameter	Symbol		Values		11:4	Note / Took Condition
		Min.	Тур.	Max.	Unit	Note / Test Condition
Drain-source breakdown voltage	V _{(BR)DSS}	30	-	-	V	V _{GS} =0 V ,I _D =1 mA
Gate threshold voltage	$V_{\rm GS(th)}$	1	-	2.2	V	V _{DS} =V _{GS} , I _D =250 μA
Zero gate voltage drain current	I _{DSS}	-	0.1	2	μΑ	V _{GS} =0 V , V _{DS} =30 V
Gate-source leakage current	I_{GSS}	-	10	100	nA	V _{GS} =20 V ,V _{DS} =0 V
Drain-source on- resistance	R _{DS(on)}	-	10.3 ²⁾	50 ³⁾	mΩ	V _{GS} =10 V ,I _D =2.0 A
Reverse diode forward on-voltage	V _{SD}	-	0.86	1.1	V	V _{GS} =0 V ,I _F =1A

3) limited by wafer test-equipment

 $^{^{1)}}$ packaged in a PG-TO263-7 (see ref. product) typical bare die $R_{\rm DS(on)}$; $V_{\rm GS}$ =10 V, when used with 4x500µm Al-wedge double stitch bonding



3 Package Outlines

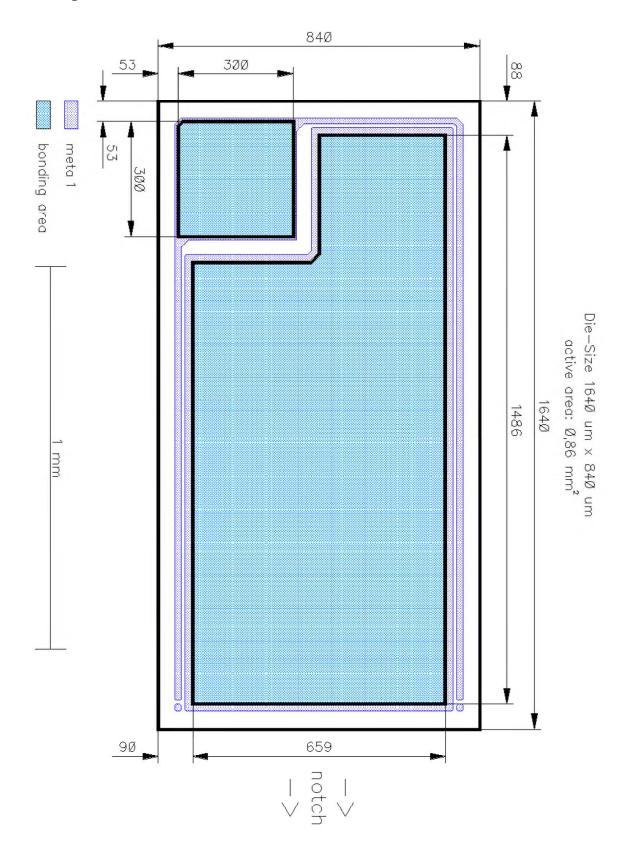


Figure 1 Outline Chip, dimensions in µm



OptiMOS™3 Power MOS Transistor Chip

IPC014N03L3

Revision History

IPC014N03L3

Revision: 2014-10-03, Rev. 2.5

Previous Revision				
Revision	Date	Subjects (major changes since last revision)		
2.5	2014-10-03	Release Final Version		

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